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PATENT
ATTORNEY DOCKET NO.: 053785-5028-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	Confirmation No.: 4663
)	
Se-Jin CHUNG)	Group Art Unit: 1722
)	
Application No.: 10/689,030)	Examiner: F.C. Hiteshew
)	
Filed: October 21, 2003)	
)	
For: EXCIMER LASER CRYSTALLIZATION)	
OF AMORPHOUS SILICON FILM)	

Commissioner for Patents
U.S. Patent and Trademark Office
Alexandria, VA 22314

Sir:

RESPONSE TO ELECTION/RESTRICTION REQUIREMENT

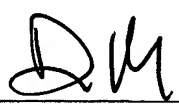
In response to the restriction requirement set forth in the Office Action mailed March 29, 2005, the period for response to which extends through April 29, 2005, Applicant elects the invention defined by the Examiner as Group I, claims 14-18, for examination on the merits.

Except for issue fees payable under 37 C.F.R. §1.18, the Commissioner is hereby authorized by this paper to charge any additional fees during the entire pendency of this application including fees due under 37 C.F.R. §1.16 and 1.17 which may be required, including any required extension of time fees, or credit any overpayment to Deposit Account 50-0310.

Respectfully submitted,

MORGAN, LEWIS & BOCKIUS LLP

Dated: April 22, 2005

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